

**"Damage Resistant Photomask  
Construction"**

Inventors: H. Ufuk Alpaya, et al.  
Atty. Docket No. 064441.0223

1/5

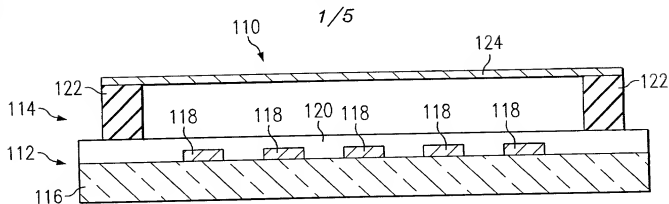


FIG. 1

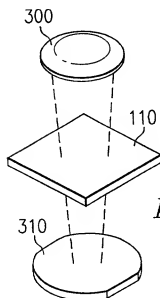


FIG. 2

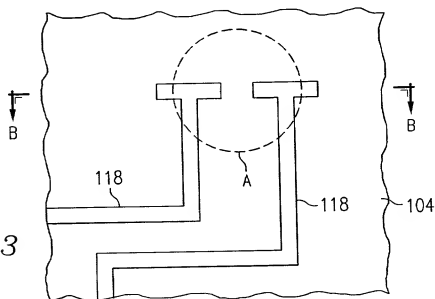


FIG. 3

FIG. 4A

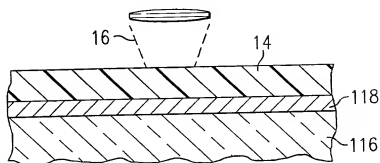


FIG. 4B

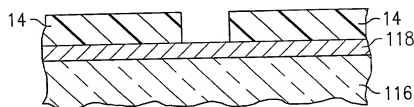


FIG. 4C

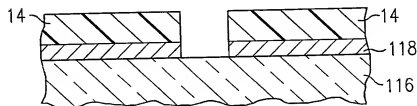
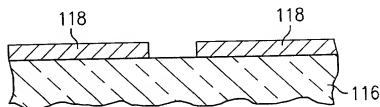


FIG. 4D



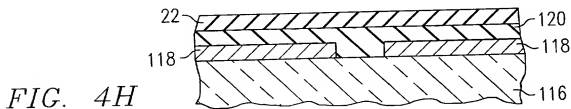
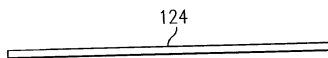
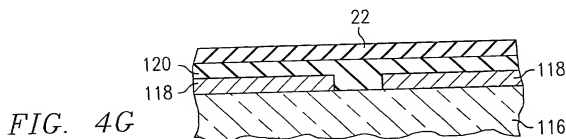
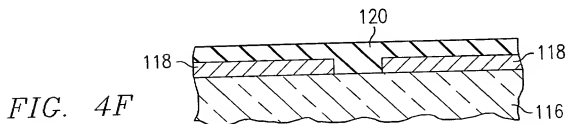
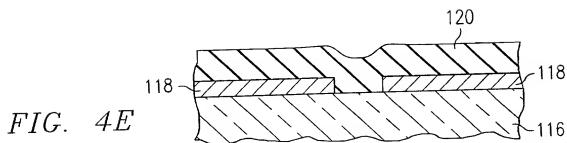


FIG. 5A

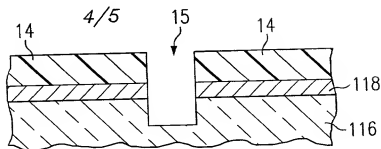


FIG. 5B

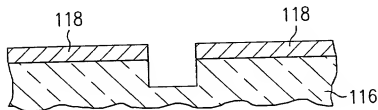


FIG. 5C

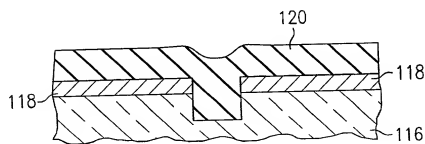


FIG. 5D

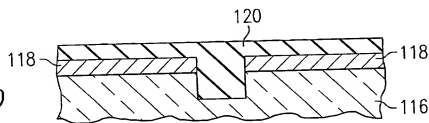
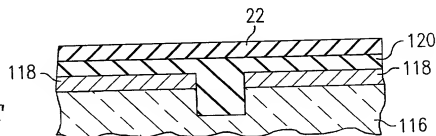


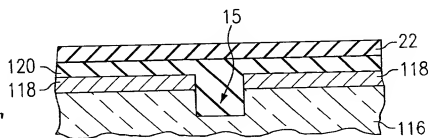
FIG. 5E



124



FIG. 5F



5/5

FIG. 6

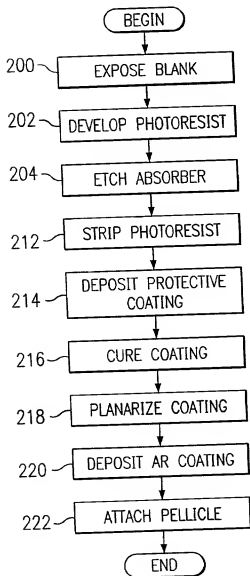


FIG. 7

